TECHNOLOGY

NEXT GENERATION METALLISATION

Common techniques for printing electronics still face challenges related to inks and process. Dr. Klaus Mertens and Dr. Kristina Lovrek introduce a new technology for metallisation that combines plasma-based curing with nanoparticle-free conductive inks



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Printed electronics have introduced huge advantages to the production of electronics, especially related to the deposition and utilisation of functional materials. While problems with deposition remain, for example, the clogging of printer nozzles and the relatively complicated process of producing the widespread nanoparticle-based inks, inkjet printing as an additive method has clear advantages such as efficient use of materials, low energy consumption and the absence of large amounts of harsh substances.

What has remained largely untouched by the printing revolution, however, are approaches to curing of metal layers. The



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conventional way is to use heat, which can damage delicate substrates such as paper, textiles, or polymers. As a result, while metals can in principle be printed onto nearly every of forming a metal layer based on Tollens' reagent [German scientist Bernhard Tollens' 'silver-mirror' test to distinguish between an aldehyde and a ketone]. Still lesser known is a novel technology using cold plasma which turns precious metal inks into high performance metal layers. Even better, the inks that this technology requires are nanoparticle-free. So the technology hits two birds with one stone – improved processing and avoiding nanoparticles.

PRINTED ELECTRONICS AND THE CURING CHALLENGE

The advantages of printing electronic components are too numerous to list them all. Where frequent changing of pattern is a must, such as piloting, the advantages are obvious. But even for mass production, a concise and material-saving process (metal application is additive, not reductive) has advantages that are hard to ignore, especially when printing with expensive precious metals such as platinum or gold. Finally, with the environmental footprint of production

"Established curing methods limit the range of substrates that are effectively used for printed electronics"

material, established curing methods limit the range of substrates that are effectively used for printed electronics.

The first answers to this curing challenge are starting to emerge. Newer approaches for room-temperature processing use UV light and high-energy photonic light. For silver inks, there is also a chemical process



Plasma enables metal coating of various 3D shapes. This image shows a comparison of non-coated and coated 3D-printed PLAbased abstract art. Image reproduced with permission from OreITech

processes getting more and more attention, low-waste printing techniques increasingly gain importance compared to 'traditional' metallisation techniques.

Unfortunately, the gains of printing come at a price. A common hurdle is the price of materials. Even the most sophisticated metal inks are still based on nanoparticles. The production of nanoparticles is time and resource-consuming, and the process produces significant chemical waste. While for the most widely used silver nanoparticle inks production cost may remain within reasonable limits, prices of inks with palladium, platinum or gold nanoparticles can be prohibitive.

Cost aside, printed electronics face a number of process-related challenges because of which printing is unlikely to ever outperform large-scale sputtering lines, e.g. for ITO [indium tin oxide] application in display production. While some first movers in the display industry are experimenting with printing lines, this is still a niche phenomenon. Reasons include the fact that printing is still much slower, especially when the marketdominating nanoparticle-based inks clog *Continued over*



Inkjet-printed silver electrode on fabric. Image reproduced with permission from OrelTech

printheads every so many metres forcing the production line to be stopped. The other 'showstopper' for continuous R2R [roll to roll] occurs wherever the printed inks require heat-based curing. Drying times can be several minutes up to one hour long, which interrupts even the slowest R2R flow.

"OrelTech's nanoparticlefree inks offer an innovative alternative to existing technologies"

So notwithstanding many obvious advantages, common techniques for printing electronics still face challenges related to inks and process, and there is a curing challenge that deserves closer attention.

ALTERNATIVES TO HEAT-BASED CURING

One promising alternative to curing with heat is light-based processing such as UV-based curing and photonic sintering. UV inks are high in viscosity and therefore suitable for high-speed techniques such as screen printing, flexography and rotogravure. UV light curing can take place at low temperatures



Transparent silver electrode inkjet printed on PET. A working prototype of such an electrode outperformed a reference ITO-based OLED device (M. Hengge et al, Flex. Print. Electron. 6 (2021) 015009). Image reproduced with permission from OrelTech



Inkjet-printed gold electrode on paper. Image reproduced with permission from OrelTech

and relatively fast. It has been successfully used e.g. for printed RFID [radio frequency identification] antennas. One challenge to overcome with UV inks is enhancing the purity of the resulting layer. Light-cured coatings contain a significant share of polymer residuals which impairs functional properties, most notably conductivity per volume.



Photonic sintering is unbeaten in terms of speed. The ink reduces to metal within microseconds. However, the stress on the substrate is locally similar to heat-based methods due to the high-energy nature of the light source. This makes the second main drawback apparent: the high cost and negative environmental impact of the high energy consumption.

A relatively new alternative to heat-based curing is the use of cold argon plasma. This technology may sound deceivingly complex, while in fact it is not. Plasma is already widely utilised in the industry, most commonly for cleaning, surface activation or in some other production step and the machines needed for the plasma curing are the same already widely implemented machines, so-called 'plasma cleaners' or 'plasma etchers'.

Plasma can be a very gentle surface technique, often affecting just a top few atomic layers, changing their chemical nature

TECHNOLOGY

or completely removing them. The gas temperature of cold plasma barely exceeds ambient conditions, and the treatment is used not to burn the surface, but to modify or activate it. That is why it is perfect for the activation of sensitive, functional materials.

When used as a conductive ink processing technique, metal layers are achieved at temperatures below 70°C under fast processing times and without chemical waste left behind. An additional advantage is the overall degree of control over the treatment process. Plasma systems are turned on and off instantaneously, and the parameters are easily tunable. Finally, the technology enables even coating of non-flat, porous or 3D structures, offering a replacement for certain processing steps from another industry with well-established methods and processes, of course, none of them flawless – namely, electroplating. Factoring in today's need to cut energy, processing times and overall waste, plasma curing is by far the 'greenest' curing technology currently available.

RE-THINKING INK FORMULATION AND CURING

A highly interesting metallisation technology combines the advantages of plasma-based curing and nanoparticle-free inks. It has been developed by scientists formerly at the Weizmann Institute in Israel and has, as the proprietary core technology of Berlin-based company OrelTech, started to prove a solution of choice for applications ranging from simple printed electrodes, printed devices like (flexible) OLEDs and solar cells, gold electrodes for biosensors and e-textiles. It is even used in plating on plastics for direct metallisation of plastic parts to create protective, catalytic and decorative coatings. The ink portfolio currently available contains silver, palladium, platinum and gold.

So what is the essence of this technology? As previously stated, the two obvious differentiating features are the absence of nanoparticles in the ink formulation, and plasma curing. During the process, a near-100% pure metal layer is directly grown on the substrate. This is fundamentally different from nanoparticle layers. Think about the difference between snow and ice. A layer formed of nanoparticle inks resembles snow: many singular particles sit more or less loosely connected on top of the substrate. In layers formed with OreITech inks, the metal is like ice – it grows directly on the surface and forms a uniform layer. This often leads to better adhesion, better cohesion, higher stability and lower surface roughness. In practical terms, this means the metal layers are thinner, more flexible, and can even be transparent while maintaining high levels of conductivity.

As for the curing, the only process step required after applying the ink is exposure to an argon plasma with slight underpressure (no strong vacuum needed) for times as short as two minutes. Therefore, the technology can be run on continuous R2R lines at moderate speeds. Sheet-by-sheet and stack-by-stack (S2S) processes are even easier to implement.

Whether OrelTech's nanoparticle-free inks are the technology for next-generation metallisation remains to be seen. They certainly offer an innovative alternative to existing technologies, especially where heat is a problem for the substrate, functional properties such as conductivity, purity, flexibility and transparency are important, and where precision in production is more important than speed.

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